L	Hits	Search Text	DB	Time stamp
Number			ļ	
_	208	spacer with coat\$ and (445/24 or 313/422	USPAT	2003/04/28
		or 313/309)		15:08
-	19	(spacer with coat\$ and (445/24 or 313/422	USPAT	2003/04/28
		or 313/309)) and spacer same silicon with		15:19
		(cvd or vapor or DMSDMA or		
	_	dimethylsilyld\$)		
-	0	(spacer with coat\$ and (445/24 or 313/422	USPAT	2003/04/28
		or 313/309)) and spacer same silicon with		15:19
		(cvd or vapor or DMSDMA or		
		dimethylsilyld\$) not ((spacer with coat\$		
		and (445/24 or 313/422 or 313/309)) and		
		spacer same silicon with (cvd or vapor or		
_	2	DMSDMA or dimethylsilyld\$))	110000	2002/04/20
-	۷	spacer same resist and spacer with (cvd	USPAT	2003/04/28
		or vapor or DMSDMA or dimethylsilyld\$)		15:22
	0	and display adj panel spacer same resist and posts with (cvd or	USPAT	2003/04/28
	O	vapor or DMSDMA or dimethylsilyld\$) and	USPAI	15:22
		display adj panel		13.22
-	1	spacer same resist and posts with (cvd or	USPAT	2003/04/28
	-	vapor or DMSDMA or dimethylsilyld\$) and	OSIAI	15:24
		display adj panel		13.21
-	1	spacer same photoresist and (posts with	USPAT	2003/04/28
		(cvd or vapor or DMSDMA or		15:27
		dimethylsilyld\$)) and display adj panel		
-	363	313/422 and (CDV or vapor or chemical or	USPAT	2003/04/28
		deposition)		15:29
-	210	(313/422 and (CDV or vapor or chemical or	USPAT	2003/04/28
		deposition)) and spacer		15:30